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| INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i> | | | | ATTY. DOCKET NO. 99B014 | | SERIAL NO. 09/574,432 | |
| | | | | APPLICANT Gary David Mohr et al. | | | |
| | | | | FILING DATE May 20, 2000 | | GROUP 1754 | |

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| U.S. PATENT DOCUMENTS | | | | | | | |
|-----------------------|-----------------|------|------|-------|----------|----------------------------|--|
| *EXAMINER INITIAL | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE | |
| | AA | | | | | | |
| | AB | | | | | | |
| | AC | | | | | | |
| | AD | | | | | | |
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| FOREIGN PATENT DOCUMENTS | | | | | | | |
|--------------------------|-----------------|------------|---------|-------|----------|-------------|----|
| | DOCUMENT NUMBER | PUBL. DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION | |
| | | | | | | YES | NO |
| Jew | AK | WO96/07713 | PCT | — | — | | |
| Jew | AL | WO00/00287 | PCT | — | — | | |
| | AM | | | | | | |

| OTHER DISCLOSURES (Including Author, Title, Date, Pertinent Pages of Publication, Etc.) | | |
|---|----|---|
| Jew | AP | Tosheva L et al.: "Silicate-1 containing microspheres prepared using shape-directing macro-templates", Microporous and Mesoporous Materials, US, Elsevier Science Publishing, New York, vol. 35-36, April 2000, pages 621-629, XP004194501; ISSN: 1387-1811; the whole document |
| | AQ | |

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| EXAMINER <i>Timothy Vanczy</i> | DATE CONSIDERED Sept. 4, 2001 |
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*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609. Draw line though citation if not in conformance and not considered. Include copy of this form with next comment to applicant